

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No. 10/531,208

Confirmation No. 6424

In re Application of

MITSURU UEDA, et al.

Art Unit: 1795

Filed: April 14, 2005

Examiner: Sin J. Lee

For: PHOTORESIST BASE MATERIAL, METHOD FOR PURIFICATION THEREOF, AND PHOTORESIST

COMPOSITIONS

US PATENT AND TRADEMARK OFFICE Customer Service Window - Mail Stop AF Randolph Building 401 Dulany Street Alexandria, Virginia 22313-1450

PETITION FOR EXTENSION OF TIME

Applicants hereby petition the Commissioner for any and all extensions of time necessary within which to file the accompanying Amendment.

The Commissioner is authorized to charge \$120 to the Deposit Account 19-4293 for the one-month extension fee. Should this fee be in error, the Commissioner is hereby authorized to debit or credit Deposit Account 19-4293.

04/14/2008 HLE333

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120.00 DA

Respectfully submitted,

April 11, 2008

Roger W. Parkhurst Registration No. 25,177 Houda Morad

Reg. No. 56,742

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